

10th ISSP International Symposium on Nanoscience at Surfaces

October 9-13, 2006 Kashiwa Campus of the University of Tokyo, Chiba, Japan

Scope of the Symposium

10th ISSP International Symposium on Nanoscience at Surfaces is the tenth in a series of international symposia organized by the Institute for Solid State Physics (ISSP), the University of Tokyo every two or three years. This symposium will focus on physical and chemical properties of nanostructures on surfaces and their fabrication processes. Research activity in this field has been growing very rapidly taking advantage of accumulated knowledge of surface science. It is highly desirable that active researchers report new advancements in this field, exchange novel ideas, and discuss directions of new researches in this symposium.

Topics

Nanostructure formation Structures and electronic states Electronic transport and magnetic properties Chemical reaction and dynamics Nanometer-scale oxide and molecular layers New developments in theory and experiment

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